

## IN THE CLAIMS

This listing of claims will replace all prior versions, and listings, of claims in the application:

- 1           1.       (Currently Amended) A current-in-plane (CIP) GMR sensor, comprising:  
2           a GMR sensor stack having a width selected to provide a predetermined track  
3       width;  
4           a spacer layer, having a width substantially equal to the spin valve stack, formed  
5       over a free-layer of the GMR sensor stack; ~~and~~  
6           an in-stack biasing layer disposed over the spacer and having a width substantially  
7       equal to the width of the GMR sensor stack; and  
8           an antiferromagnetic layer formed on both sides of the in-stack biasing layer to  
9       provide an off-track bias layer.
- 1           2.       (Previously Presented)       The CIP GMR sensor of claim 1, wherein  
2       the in-stack biasing layer comprises materials selected from the group consisting of NiFe,  
3       CoFe, NiFeCr, NiFeX and CoFeX.
- 1           3.       (Canceled)
- 1           4.       (Currently Amended) The CIP GMR sensor of claim [[ 3 ]] 1, further  
2       comprising lead layers formed on either side of the GMR sensor stack, wherein the lead  
3       layers comprises a layer of Rhodium disposed adjacent to the GMR sensor stack and a  
4       Tantalum layer formed over the layer of Rhodium.

1           5.       (Currently Amended) The CIP GMR sensor of claim [[ 3 ]] 1, wherein the  
2   antiferromagnetic layer comprises a layer of Platinum-Manganese.

1           6.       (Currently Amended) The CIP GMR sensor of claim [[ 3 ]] 1, wherein the  
2   in-stack biasing layer comprises a bias layer formed only over the spacer and a coupling  
3   layer formed over the bias layer and the antiferromagnetic layer.

1           7.       (Previously Presented)       The CIP GMR sensor of claim 6, wherein  
2   the bias layers and coupling layer each comprise a material selected from the group  
3   consisting of NiFe, CoFe, NiFeCr, NiFeX and CoFeX.

1           8.       (Original)       The CIP GMR sensor of claim 1 further comprising a cap  
2   layer formed over the in-stack bias layer.

1           9.       (Currently Amended) A magnetic storage system, comprising:  
2           a magnetic storage medium having a plurality of tracks for recording of data; and  
3           a current-in-plane (CIP) GMR sensor maintained in a closely spaced position  
4       relative to the magnetic storage medium during relative motion between the magnetic  
5       transducer and the magnetic storage medium, the CIP GMR sensor further comprising:  
6           a GMR sensor stack having a width selected to provide a predetermined  
7       track width;  
8           a spacer layer, having a width substantially equal to the spin valve stack,  
9       formed over a free-layer of the GMR sensor stack; ~~and~~  
10          an in-stack biasing layer disposed over the spacer and having a width  
11       substantially equal to the width of the GMR sensor stack; and  
12          an antiferromagnetic layer formed on both sides of the in-stack biasing  
13       layer to provide an off-track bias layer.

1           10.       (Previously Presented)       The magnetic storage of claim 9, wherein  
2       the in-stack biasing layer comprises materials selected from the group consisting of NiFe,  
3       CoFe, NiFeCr, NiFeX and CoFeX.

1           11.       (Canceled)

1           12.     (Currently Amended) The magnetic storage of claim [[ 11 ]] 9, further  
2     comprising lead layers formed on either side of the GMR sensor stack, wherein the lead  
3     layers comprises a layer of Rhodium disposed adjacent to the GMR sensor stack and a  
4     Tantalum layer formed over the layer of Rhodium.

1           13.     (Currently Amended) The magnetic storage of claim [[ 11 ]] 9, wherein  
2     the antiferromagnetic layer comprises a layer of Platinum-Manganese.

1           14.     (Currently Amended) The magnetic storage of claim [[ 11 ]] 9, wherein  
2     the in-stack biasing layer comprises a bias layer formed only over the spacer and a  
3     coupling layer formed over the bias layer and the antiferromagnetic layer.

1           15.     (Currently Amended) The magnetic storage of claim [[ 9 ]] 14, wherein  
2     the bias layer and the coupling layer each comprise a material selected from the group  
3     consisting of NiFe, CoFe, NiFeCr, NiFeX and CoFeX.

1           16.     (Original)     The magnetic storage of claim 9 further comprising a cap  
2     layer formed over the in-stack bias layer.

1           17.     (Currently Amended) A method for providing a current-in-plane (CIP)  
2     GMR sensor with an improved in-stack bias layer with a thinner sensor stack,  
3     comprising;  
4           forming a thin spin valve stack having a width selected to provide a  
5     predetermined track width;  
6           forming a spacer over the spin valve stack, the spacer having a width substantially  
7     equal to the spin valve stack;  
8           forming lead layers in a passive region outside the track;  
9           forming, over the spacer, an in-stack bias layer having a width substantially equal  
10    to the width of the GMR sensor stack for biasing a free-layer of the spin valve stack; ~~and~~  
11           forming a cap over the bias layer; and  
12           forming an antiferromagnetic layer on both sides of the in-stack biasing layer to  
13    provide an off-track bias layer.

1           18.     (Previously Presented)       The method of claim 17, wherein forming  
2     the lead layers further comprises forming a layer of Rhodium disposed adjacent to the  
3     GMR sensor stack and forming a Tantalum layer formed over the layer of Rhodium.

1           19.     (Previously Presented)       The method of claim 17, wherein the  
2     forming of the in-stack bias layer comprises forming a layer of Platinum-Manganese.

1           20.     (Previously Presented)       The method of claim 17, wherein the in-  
2     stack bias layer comprises a bias layer formed only over the spacer and a coupling layer  
3     formed over the bias layer and the antiferromagnetic layer.

1           21.     (Currently Amended) The method of claim [[ 17 ]] 20, wherein the  
2     forming of the bias layer and the coupling layer each further comprises using a material  
3     selected from the group consisting of NiFe, CoFe, NiFeCr, NiFeX and CoFeX.